

AN 2002-323696 [36] WPIDS
DNC C2002-094211 [36]
DNN N2002-254023 [36]
TI Electrode wire for wire electrical discharge processings, comprises specific amount of tin and indium, remainder of copper and unavoidable impurity
DC M11; M23; M26; P54
IN KIMURA T; KURODA H; MATSUZAKI H; NAGAI T; SATO T; SAWAHATA K
PA (HITID-C) HITACHI CABLE LTD
CYC 1
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JP 3941352 B2 20070704 (200744) JA 9
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PRAI JP 2000-233175 20000728
AB JP 2002047520 A UPAB: 20050525
NOVELTY - The electrode wire comprises 0.01-2.40 weight% of each of indium and tin, and remainder of copper and unavoidable impurity.
DETAILED DESCRIPTION - An INDEPENDENT CLAIM is also included for the electrode wire manufacturing method.
USE - For wire electrical discharge processings of hard cutting materials such as graphite and sintered metal.
ADVANTAGE - The electrode wire of desired diameter has excellent electrical discharge processing characteristics and favorable wire drawing property.